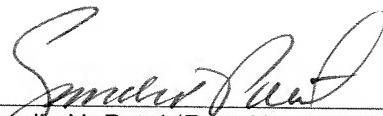


IN THE UNITED STATES PATENT  
AND TRADEMARK OFFICE

Applicants: Geun Su Lee et al. ) I hereby certify that this paper (along with  
Serial No.: 10/723,029 ) any paper referred to as being attached or  
Filed: November 26, 2003 ) enclosed) is being transmitted via EFS-  
Title: Cleaning Solution for Photoresist ) Web to the U.S. Patent and Trademark  
and Method for Forming Pattern ) Office on December 27, 2006.  
Using the Same )  
Group Art Unit: 1751 )  
Examiner: Gregory E. Webb )  
Attorney Docket No.: 30205/39714 ) Sandip H. Patel (Reg. No. 43,848)  
 ) Attorney for Applicants  
 )



RESPONSE TO OFFICIAL ACTION

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Dear Sir:

This paper is presented in response to the non-final official action dated August 28, 2006.

A complete listing of the claims begins on page 2 of this paper.

Remarks begin on page 7 of this paper.